

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	(mask and etch\$3 and planariz\$3 and trench and "capacitor trench" and (STI or "shallow trench isolation") and "hard mask").clm	US-PGPUB	OR	ON	2005/10/14 10:07
L2	17	hollatz-mark.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/14 10:08
L3	25	morhard-klaus-dieter.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/14 10:09
L4	2	truby-alexander.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/14 10:09